AMENDMENT TO THE CLAIMS

1 - 19. (Cancelled)

20. (Previously presented) A slitter apparatus comprising:

a first semi-circular member having first and second mating surfaces;

a second semi-circular member having first and second mating surfaces complimentary to the opposed first and second mating surfaces of the first member;

wherein the first member is engageable with the second member to form on engagement a cylindrical body;

a first rectangular land having a plurality of sidewall surfaces projecting from one of the first or second mating surfaces of the first member wherein the corners formed between adjacent sidewall surfaces of the first rectangular land are radiused;

a first rectangular recess having a plurality of sidewall surfaces projecting into one of the first or second mating surfaces of the second member wherein the corners formed between adjacent sidewall surfaces of the first rectangular recess are radiused;

wherein the radius of each corner formed between adjacent sidewall surfaces of the first rectangular recess is less than the radius of the corresponding corner formed between adjacent sidewall surfaces of the first rectangular land; and

wherein the first rectangular recess is interengageable with the first rectangular land to provide axial and radial alignment of the first member with the second member.

PAGE 10/18 * RCVD AT 12/22/2004 3:41:21 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-1/1 * DNIS:8729306 * CSID:6082831709 * DURATION (mm-ss):04-16

21. (Previously presented) A slitter apparatus comprising:

a first semi-circular member having first and second mating surfaces;

a second semi-circular member having first and second mating surfaces complimentary to the opposed first and second mating surfaces of the first member;

wherein the first member is engageable with the second member to form on engagement a cylindrical body;

a first rectangular land having a plurality of sidewall surfaces projecting from one of the first or second mating surfaces of the first member wherein the corners formed between adjacent sidewall surfaces of the first rectangular land are radiused;

a second rectangular land having a plurality of sidewall surfaces projecting from the other of the first or second mating surfaces of the first member wherein the corners formed between adjacent sidewall surfaces of the second rectangular land are radiused;

a first rectangular recess having a plurality of sidewall surfaces projecting into one of the first or second mating surfaces of the second member;

a second rectangular recess having a plurality of sidewall surfaces projecting into the other of the first or second mating surfaces of the second member;

wherein the first rectangular recess is interengageable with the first rectangular land to provide axial and radial alignment of the first member with the second member;

PAGE 11/18 * RCVD AT 12/22/2004 3:41:21 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-1/1 * DNIS:8729306 * CSID:6082831709 * DURATION (mm-ss):04-16

wherein the second rectangular recess is interengageable with the second rectangular land to provide axial and radial alignment of the first member with the second member; and

wherein the first rectangular land is interengageable with the first rectangular recess, and further wherein the first rectangular land is not interengageable with the second rectangular recess, whereby the first and second semi-circular members may be connected together only in one way to form the cylindrical body.

22. (Previously presented) A slitter apparatus comprising:

a first semi-circular member having a first mating surface;

a second semi-circular member having a second mating surface engageable with the first mating surface to form a cylindrical body;

a rectangular land projecting from the first mating surface of the first semi-circular member wherein the land includes no more than one planar surface substantially parallel to the first mating surface and further wherein the land includes a plurality of sidewall surfaces projecting from the first mating surface wherein the corners formed between adjacent sidewall surfaces of the rectangular land are chamfered;

a rectangular recess protruding into the second mating surface of the second semi-circular member wherein the recess includes no more than one planar surface substantially parallel to the second mating surface and further wherein the recess includes

PAGE 12/18 * RCVD AT 12/22/2004 3:41:21 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-1/1 * DNIS:8729306 * CSID:6082831709 * DURATION (mm-ss):04-16

a plurality of sidewall surfaces projecting into the second mating surface wherein the corners formed between adjacent sidewall surfaces of the rectangular recess are chamfered;

wherein the length of the chamfer on each corner formed between adjacent sidewall surfaces of the rectangular recess is less than the length of the chamfer on the corresponding corner formed between adjacent sidewall surfaces of the rectangular land; and

wherein engagement of the land with the recess provides both axial and radial alignment of the first semi-circular member with the second semi-circular member.

23. (Previously presented) A slitter apparatus comprising:

a first semi-circular member having a first mating surface;

a second semi-circular member having a second mating surface engageable with the first mating surface to form a cylindrical body;

a rectangular land projecting from the first mating surface of the first semi-circular member wherein the land includes no more than one planar surface substantially parallel to the first mating surface and further wherein the land includes a plurality of sidewall surfaces projecting from the first mating surface wherein the corners formed between adjacent sidewall surfaces of the rectangular land are radiused;

a rectangular recess protruding into the second mating surface of the second semi-circular member wherein the recess includes no more than one

PAGE 13/18 * RCVD AT 12/22/2004 3:41:21 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-1/1 * DNIS:8729306 * CSID:6082831709 * DURATION (mm-ss):04-16

planar surface substantially parallel to the second mating surface and further wherein the recess includes a plurality of sidewall surfaces projecting into the second mating surface wherein the corners formed between adjacent sidewall surfaces of the rectangular recess are radiused;

wherein the radius of each corner formed between adjacent sidewall surfaces of the rectangular recess is less than the radius of the corresponding corner formed between adjacent sidewall surfaces of the rectangular land; and

wherein engagement of the land with the recess provides both axial and radial alignment of the first semi-circular member with the second semi-circular member.

PAGE 14/18 * RCVD AT 12/22/2004 3:41:21 PM [Eastern Standard Time] * SVR:USPTO-EFXRF-1/1 * DNIS:8729306 * CSID:6082831709 * DURATION (mm-ss):04-16